

Licensing Incentive Framework for Technologies (“LIFT”): Past Use

1/6

過去分

理論上の過去分支払債務(“PUTL”)
想定料率に基づく新規ライセンシーの
理論上の過去分支払債務の決定
Past Use Theoretical Liability (“PUTL”)
Determination of new licensee Past Use Theoretical
Liability based on the assumed royalty rate

Licensing Incentive Framework for Technologies (“LIFT”): Past Use

2/6

過去分

理論上の過去分支払債務(“PUTL”)
想定料率に基づく新規ライセンシーの
理論上の過去分支払債務の決定

Past Use Theoretical Liability (“PUTL”)
Determination of new licensee Past Use Theoretical Liability based on the assumed royalty rate

係数「W」を使用し、
過去分の支払債務
(以下「PULP」)を計算

A liability coefficient “W” is used to determine the Past Use Liability Payable (“PULP”)

ライセンス市場浸透率

係数W

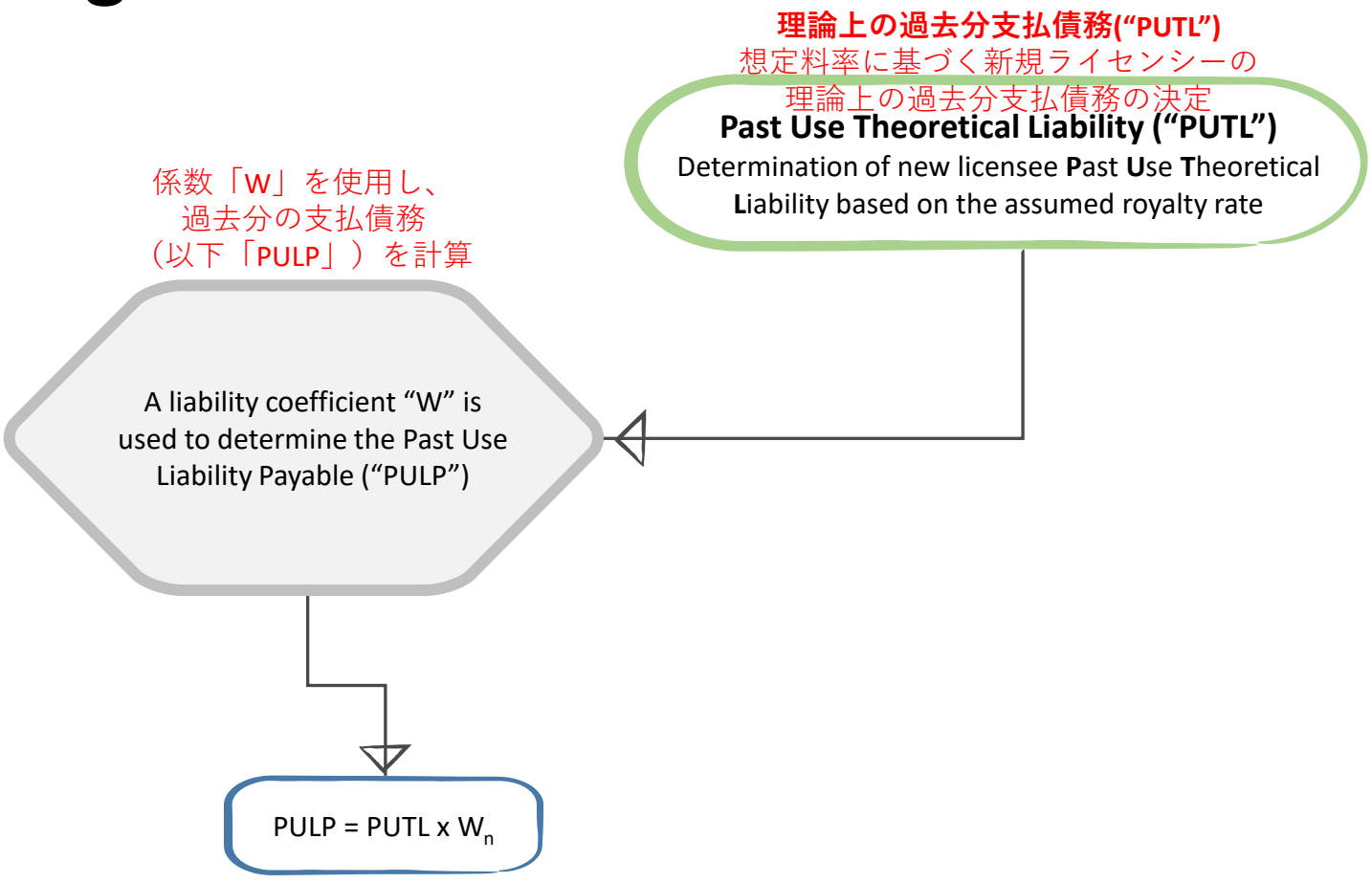
Licensable Market Penetration (“LMP”)	Coefficient W (“W”)
0% ≤ LMP < 5%	10%
5% ≤ LMP < 15%	15%
15% ≤ LMP < 25%	30%
25% ≤ LMP < 35%	45%
35% ≤ LMP < 45%	60%
45% ≤ LMP < 55%	80%
55% ≤ LMP	100%

過去分

Licensing Incentive Framework for Technologies (“LIFT”): Past Use

3/6

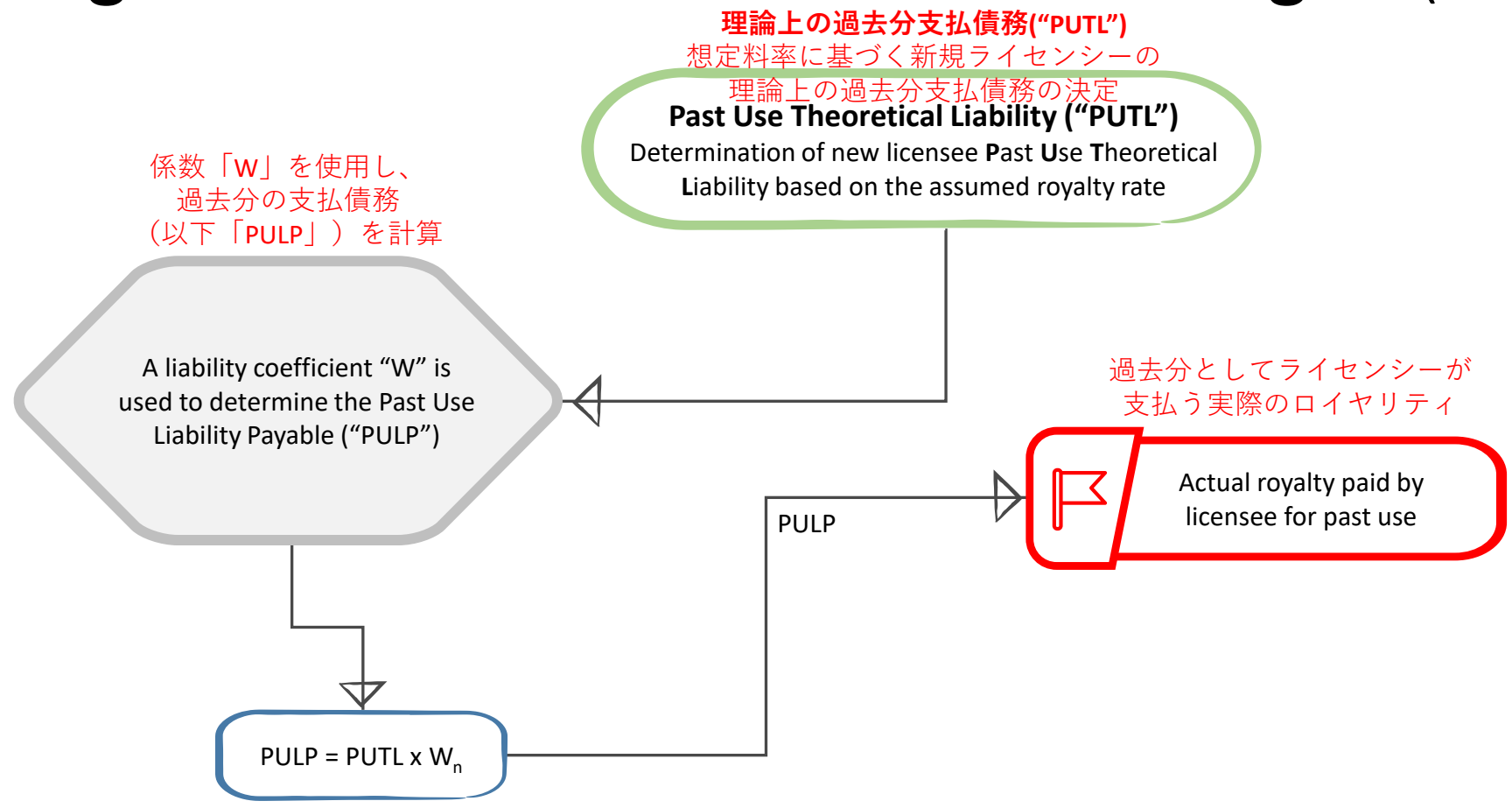
過去分



過去分

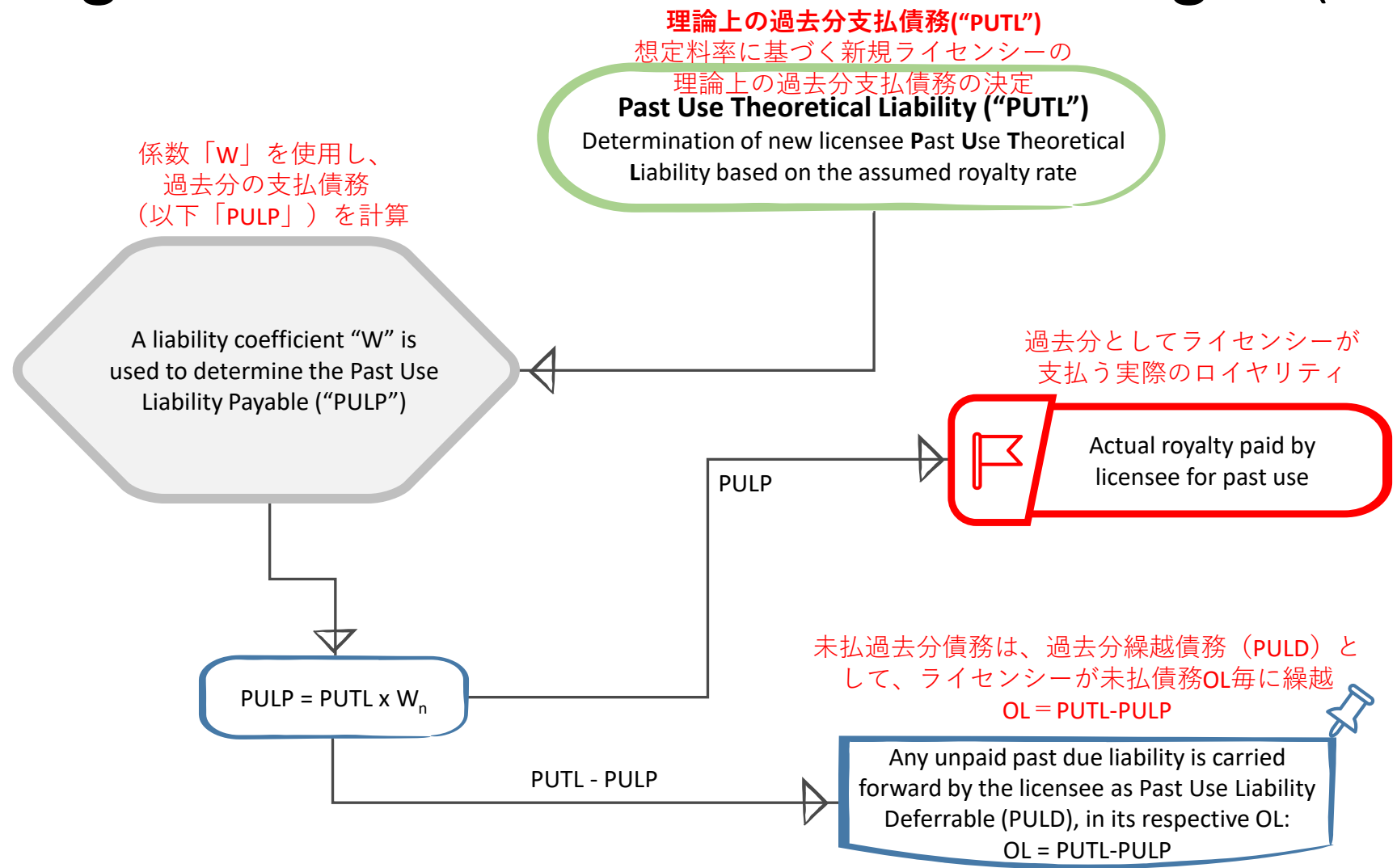
Licensing Incentive Framework for Technologies (“LIFT”): Past Use

4/6



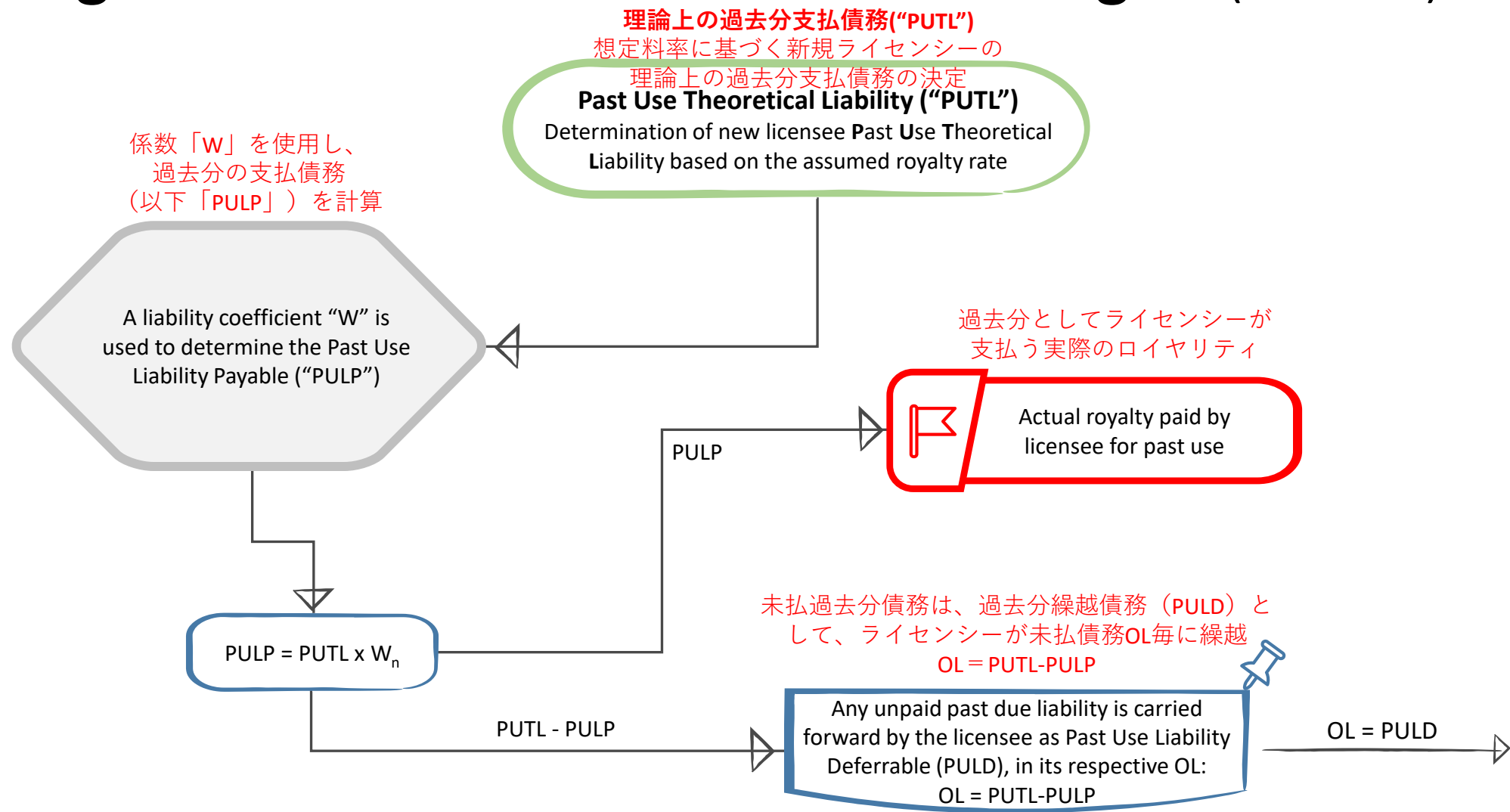
Licensing Incentive Framework for Technologies (“LIFT”): Past Use

5/6



Licensing Incentive Framework for Technologies (“LIFT”): Past Use

6/6



Licensing Incentive Framework for Technologies (“LIFT”): Running

1/10

理論上のランニングロイヤリティ支払債務(“RRTL”)
想定料率に基づき、各四半期ごとに決定

ランニング

Running Royalty Theoretical Liability (“RRTL”)
based on the assumed royalty rate is determined in each
quarter

Licensing Incentive Framework for Technologies (“LIFT”): Running

2/10

四半期ごとに決定される係数Wを使用し、ランニングロイヤリティ(RRP)と繰越ランニングロイヤリティ(RRD)を決定

A liability coefficient “W” is determined quarterly. W is used to determine both Running Royalty Payable (“RRP”) and Running Royalty Deferrable (“RRD”)

理論上のランニングロイヤリティ支払債務(“RRTL”) 想定料率に基づき、各四半期ごとに決定

Running Royalty Theoretical Liability (“RRTL”)
based on the assumed royalty rate is determined in each quarter

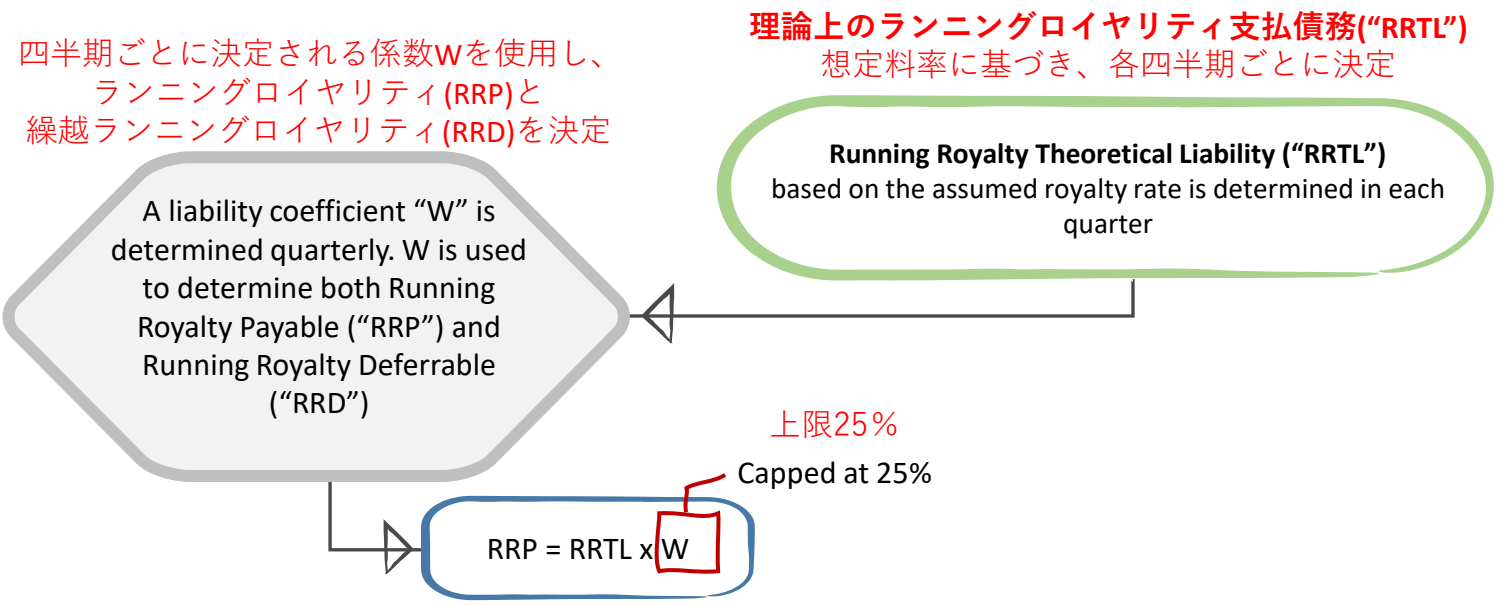
ライセンス市場浸透率

係数W

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0% ≤ LMP < 5%	10%
5% ≤ LMP < 15%	15%
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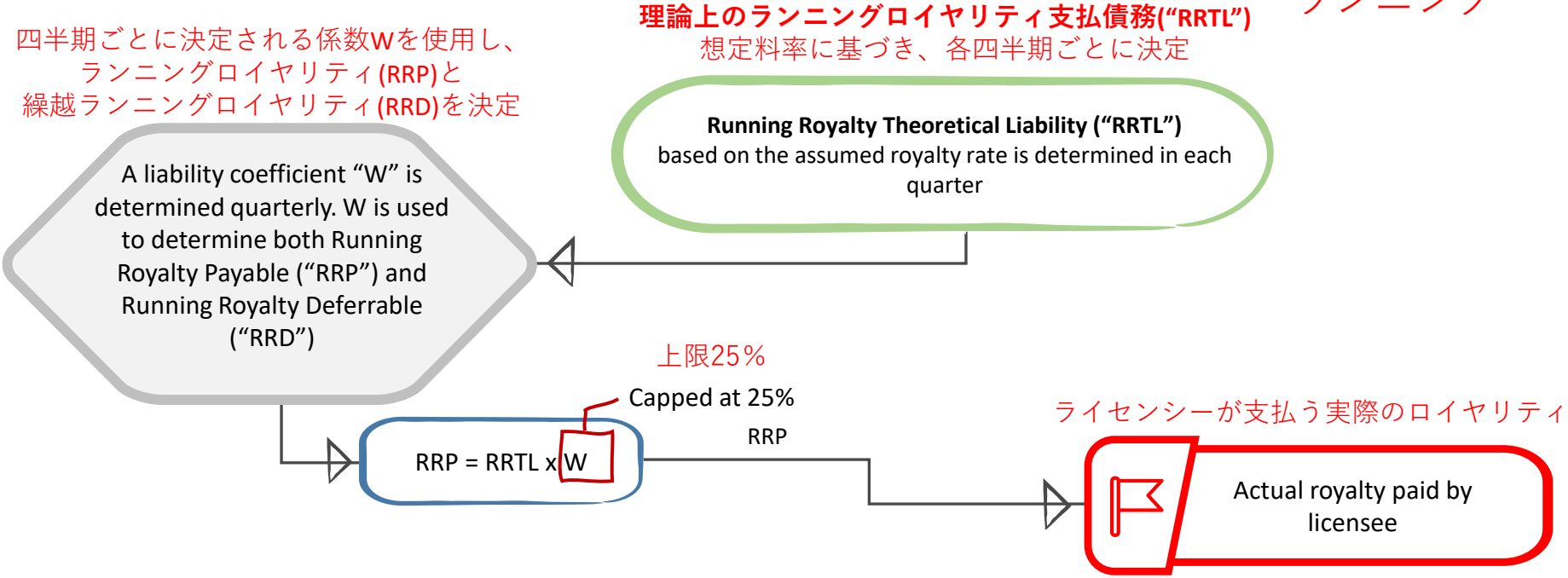
ランニング

Licensing Incentive Framework for Technologies (“LIFT”): Running 3/10



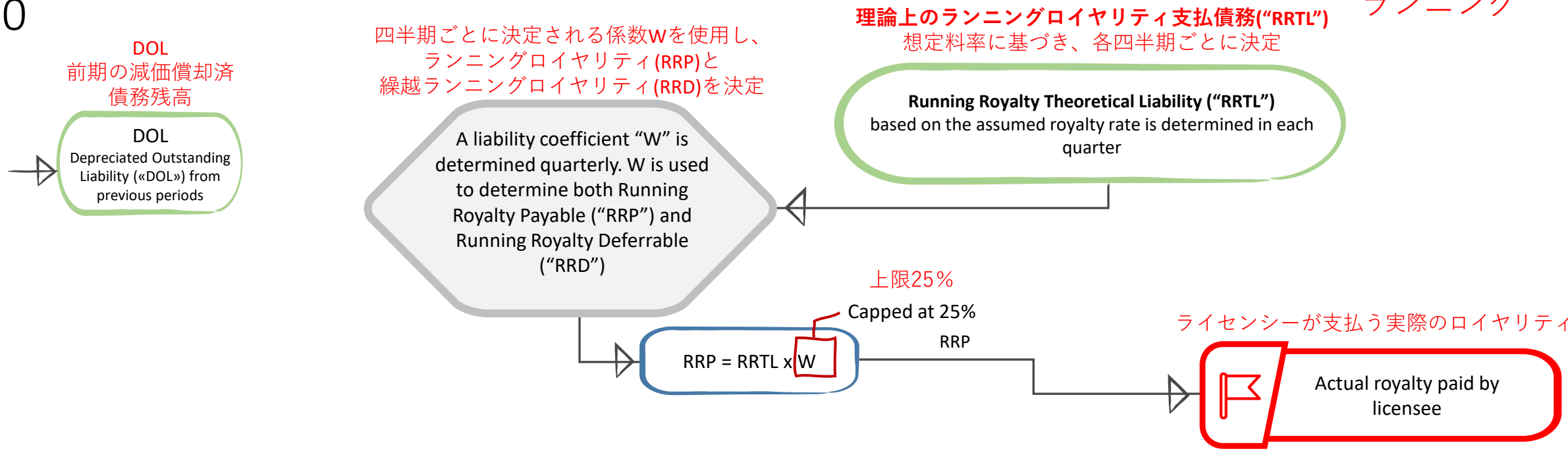
Licensing Incentive Framework for Technologies (“LIFT”): Running

4/10



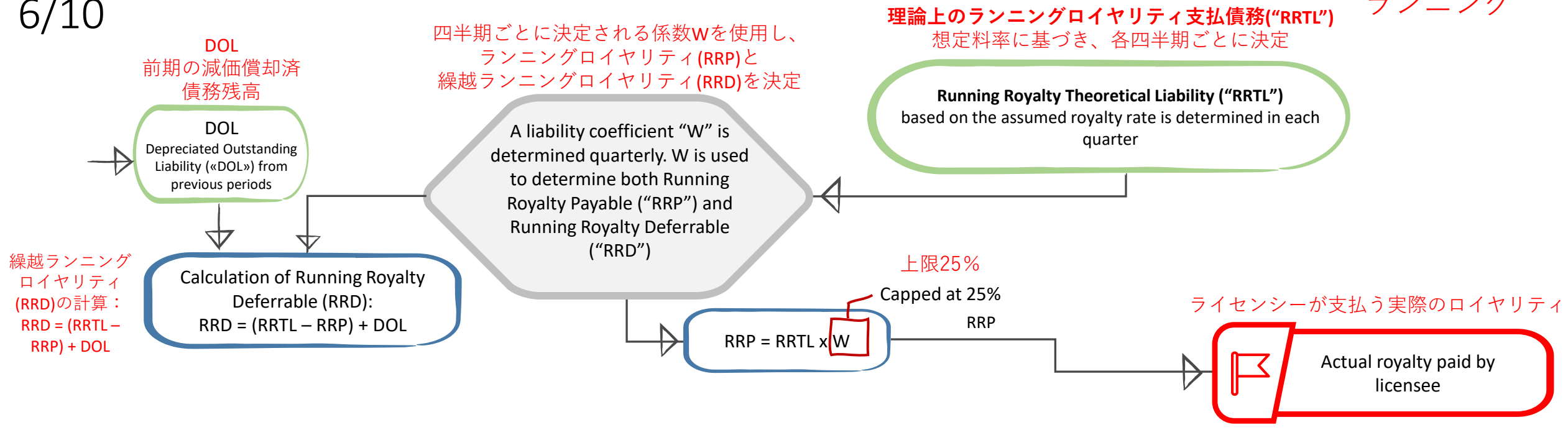
Licensing Incentive Framework for Technologies (“LIFT”): Running

5/10



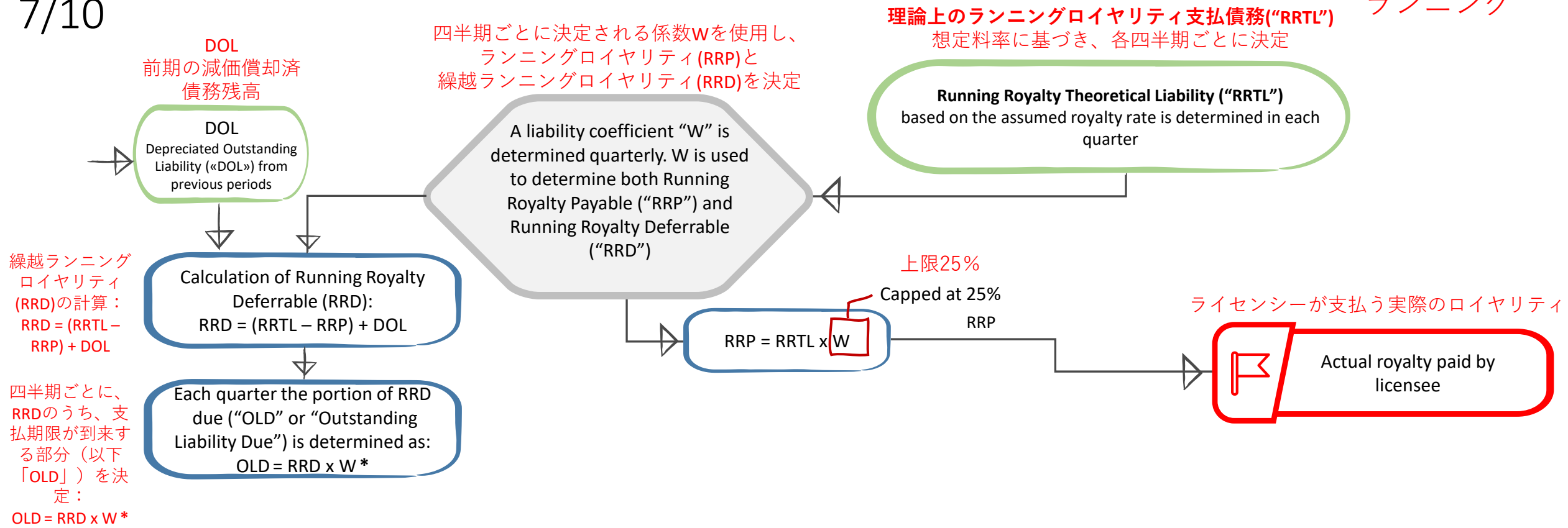
Licensing Incentive Framework for Technologies (“LIFT”): Running

6/10



Licensing Incentive Framework for Technologies (“LIFT”): Running

7/10

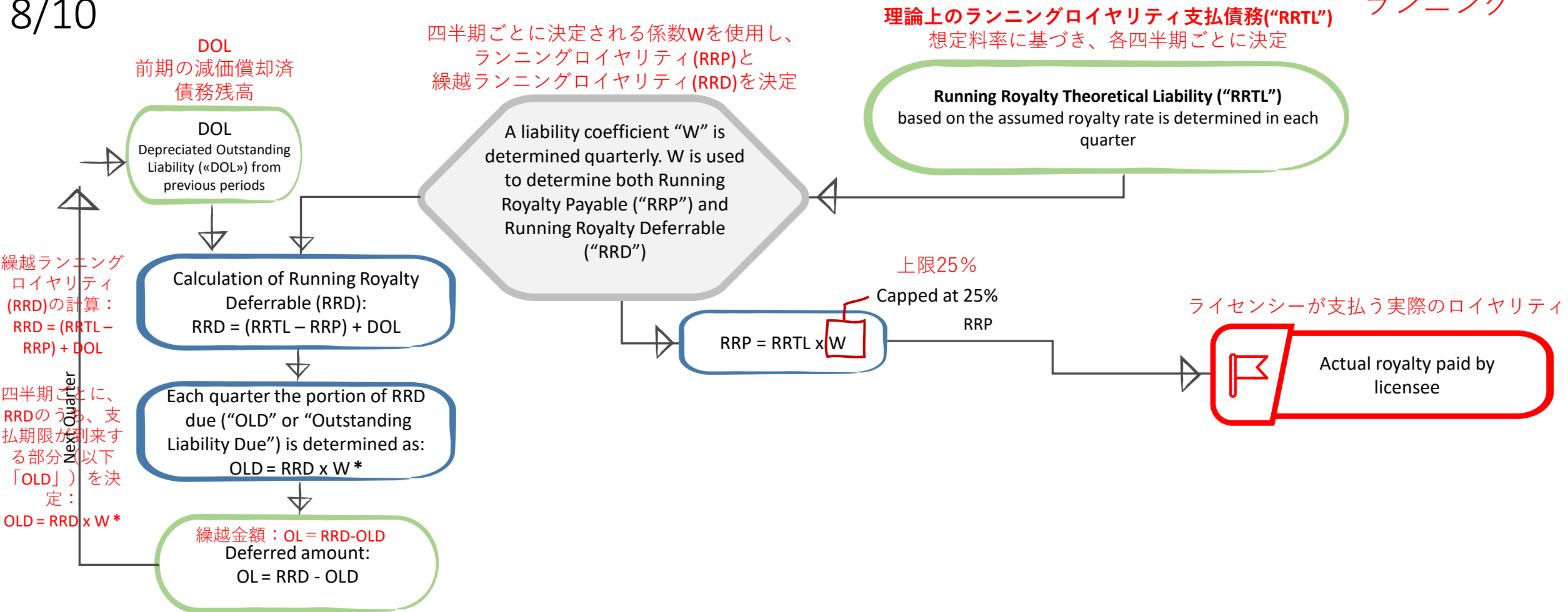


* The difference between RRD and OLD is deferred
*RRDとOLDの差額が繰り越される ランニング

Licensing Incentive Framework for Technologies – LIFT: Running

Licensing Incentive Framework for Technologies (“LIFT”): Running

8/10 ランニング



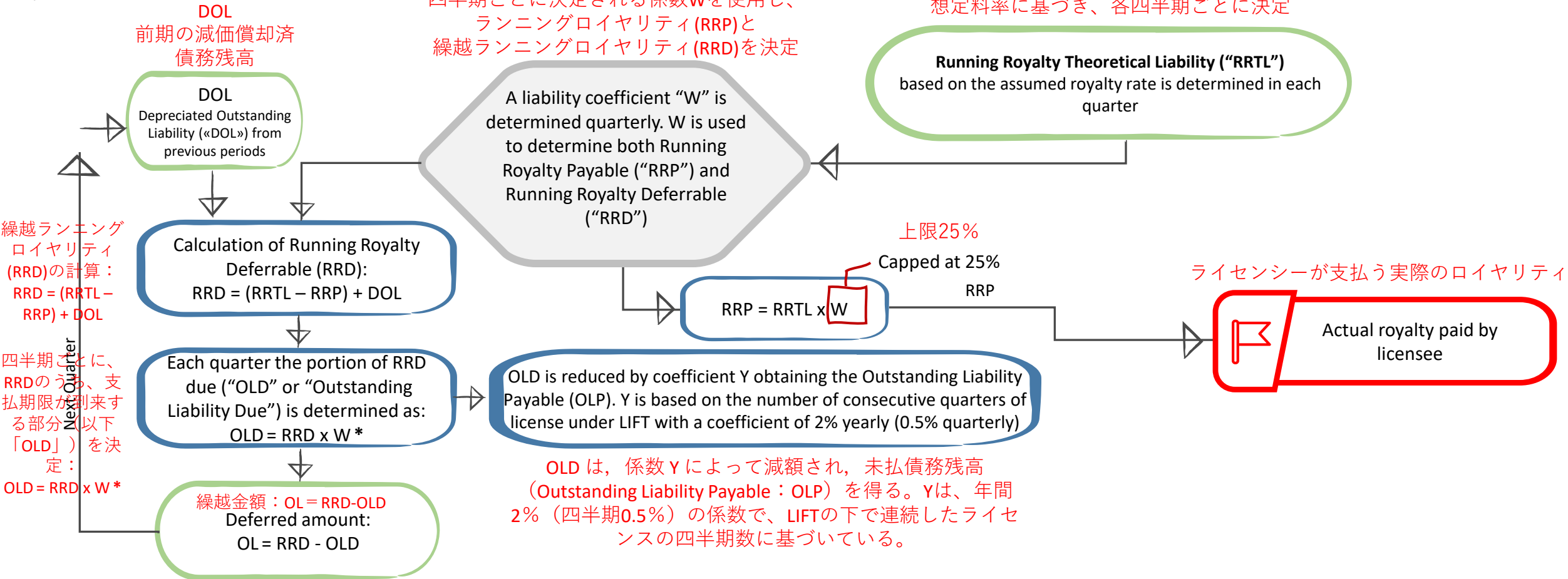
* The difference between RRD and OLD is deferred
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Licensing Incentive Framework for Technologies (“LIFT”): Running Royalty

9/10

理論上のランニングロイヤリティ支払債務(“RRTL”)
想定料率に基づき、各四半期ごとに決定

ランニング



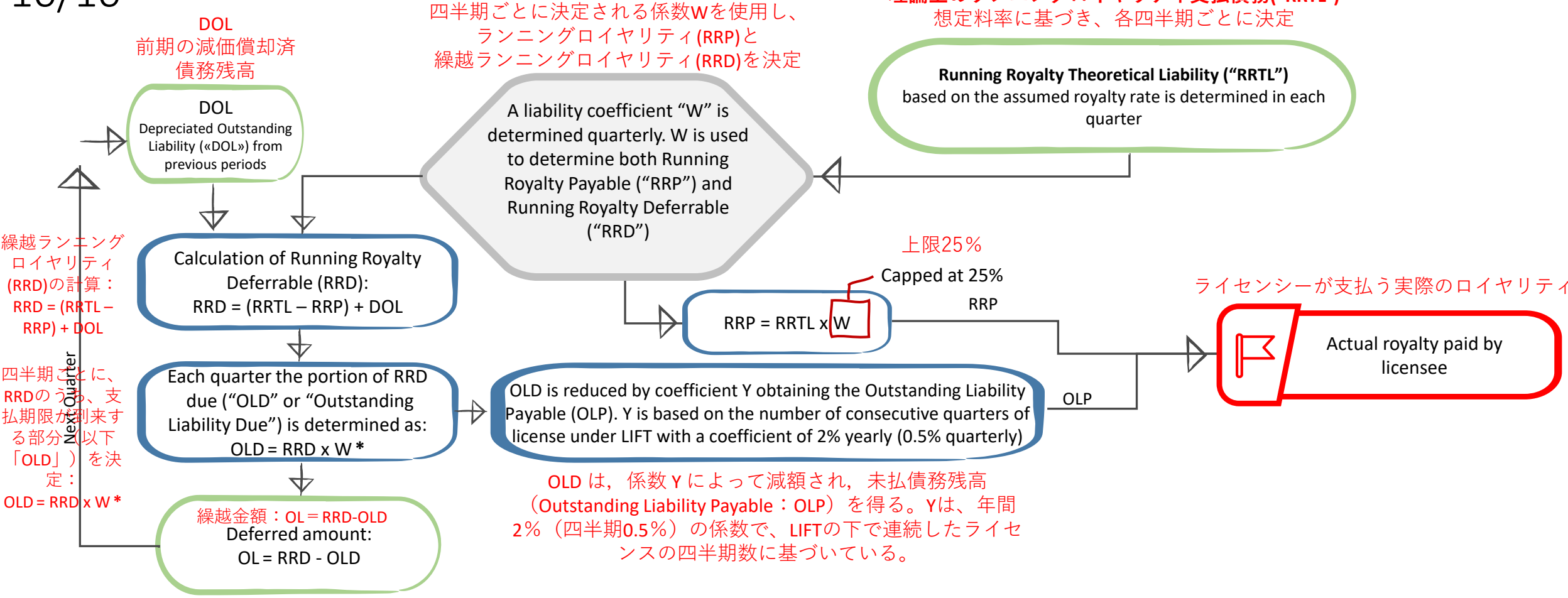
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Licensing Incentive Framework for Technologies (“LIFT”): Running Royalty

10/10

理論上のランニングロイヤリティ支払債務(“RRTL”)
想定料率に基づき、各四半期ごとに決定

ランニング



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